

The 21st American Conference on Crystal Growth and Epitaxy Santa Fe, New Mexico July 30 - August 4, 2017



Influence of Containment on the Growth of Germanium-Silicon in Microgravity

M. P. Volz¹, K. Mazuruk², A. Cröll^{2,3} T. Sorgenfrei³

¹NASA, Marshall Space Flight Center, EM31, Huntsville, Alabama, USA ²University of Alabama in Huntsville, Huntsville, Alabama, USA ³Kristallogrophie, University of Freiburg, Germany



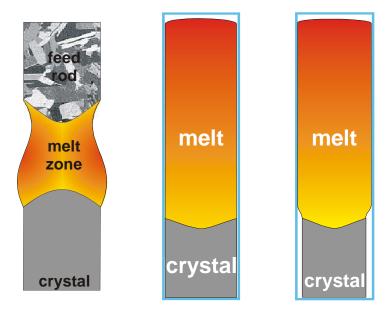


Overview of the Investigation



This investigation involves the comparison of results achieved from three types of crystal growth of germanium and germanium-silicon alloys:

- Float zone growth
- Bridgman growth
- Detached Bridgman growth



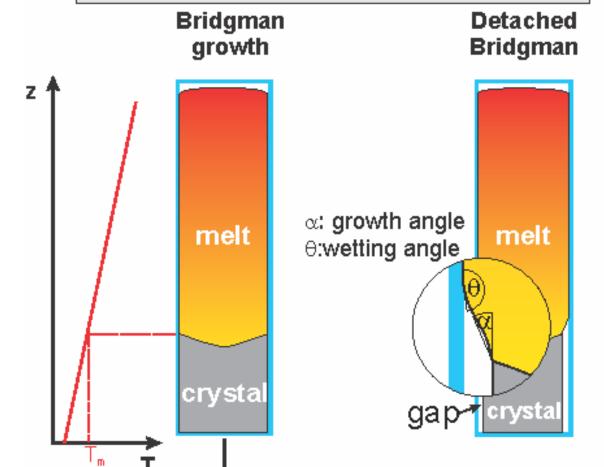
The fundamental goal of the proposed research is to determine the influence of containment on the processing-induced defects and impurity incorporation in germanium-silicon (GeSi) crystals (silicon concentration in the solid up to 5 at%) for three different growth configurations in order to quantitatively assess the improvements of crystal quality possible by detached growth.



What is Detached Bridgman Growth?







Advantages

- No sticking of the crystal to the ampoule wall
- Reduced stress
- Reduced dislocations
- No heterogeneous nucleation by the ampoule
- Reduced contamination

¹V. S. Zemskov:

Fiz. Khim. Obrab. Mater. 17 (1983) 56

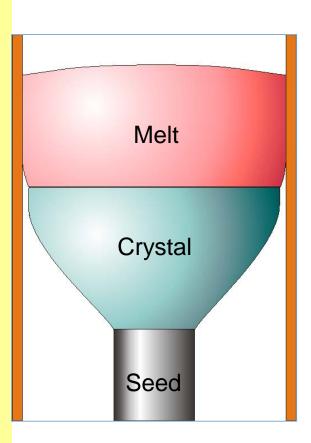
²T.Duffar, I Paret-Harter, P.Dusserre: J.Crystal Growth 100 (1990) 171.



Research Motivation



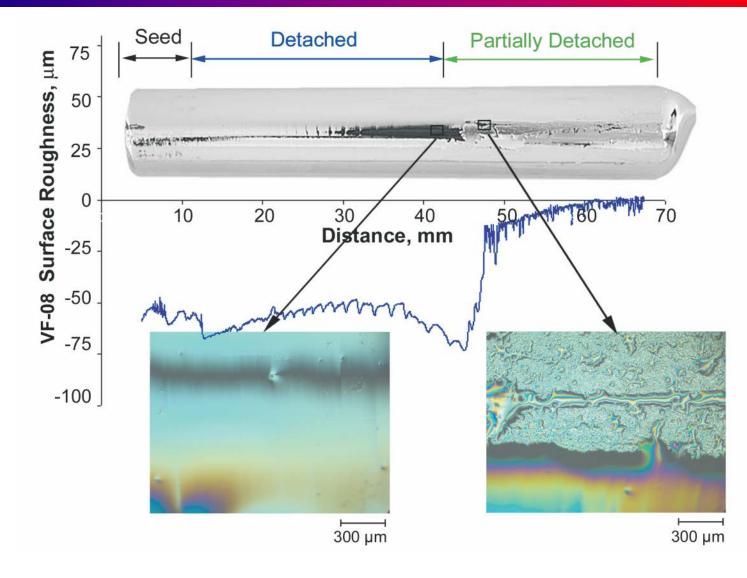
- What are the conditions for detachment in microgravity and how do they depend on the governing parameters?
 - Growth angle
 - Contact angle
 - Pressure differential
 - Bond number (ratio of gravity to capillarity)
- Which detached growth solutions are dynamically stable?
- How does an initial crystal radius evolve to one of the following states?
 - Stable detached gap
 - Attachment to the crucible wall
 - Meniscus collapse
- What are the effects of angular dependence on the crystal shape (faceting effects)?





Detached Crystal Growth







Etch Pit Densities in Detached/Attached Crystals



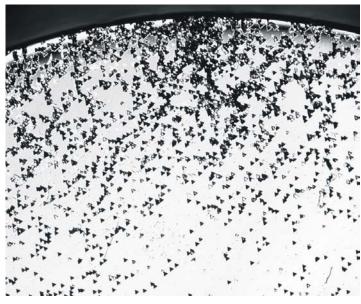
Completely detached grown crystal UMC7

<u>1mm</u>.

Attached grown crystal UMC6



EPD ≈ 200cm⁻²



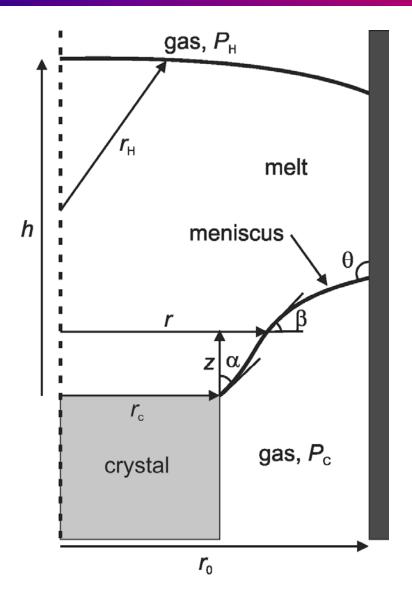
 $EPD\approx 2\cdot 10^4 cm^{-2}$

M. Schweizer, S. D. Cobb, M. P. Volz, J. Szoke, F. R. Szofran, JCG 235 (2002) 161-166



Schematic Diagram of Detached Solidification





 α : growth angle

 θ : contact or wetting angle

M. P. Volz, K. Mazuruk, *Journal of Crystal Growth* 321 (2011) 29-35



Calculation of Meniscus Shapes



$$\frac{\frac{d^2z}{dr^2}}{\left(1+\left(\frac{dz}{dr}\right)^2\right)^{\frac{3}{2}}} + \frac{\frac{dz}{dr}}{r\left(1+\left(\frac{dz}{dr}\right)^2\right)^{\frac{1}{2}}} = \Delta P - Bz(r)$$

Young-Laplace Equation

$$\Delta P = \frac{\Delta P_m r_0}{\sigma}, \quad \Delta P_m = P_H - P_C + \rho g h + 2 \frac{\sigma}{r_H}$$

$$B = \frac{\rho g_0 r_0^2}{\sigma}$$
 $B = 3.248$; Ge, $r_0 = 6$ mm $B = 4.651$; InSb, $r_0 = 5.5$ mm

 ΔP : Dimensionless pressure differential across the meniscus

B : Bond number; ratio of gravity force to surface tension force

$$\frac{\partial r}{\partial s} = \cos \beta, \quad \frac{\partial z}{\partial s} = \sin \beta, \quad \frac{\partial \beta}{\partial s} = -\frac{\sin \beta}{r} + \Delta P - Bz$$

Set of 3 coupled differential equations

Boundary Conditions

$$z(0) = 0$$
; $\beta(0) = 90^{\circ} - \alpha$;

$$\beta(1) = \theta - 90^{\circ}; r(1) = 1$$

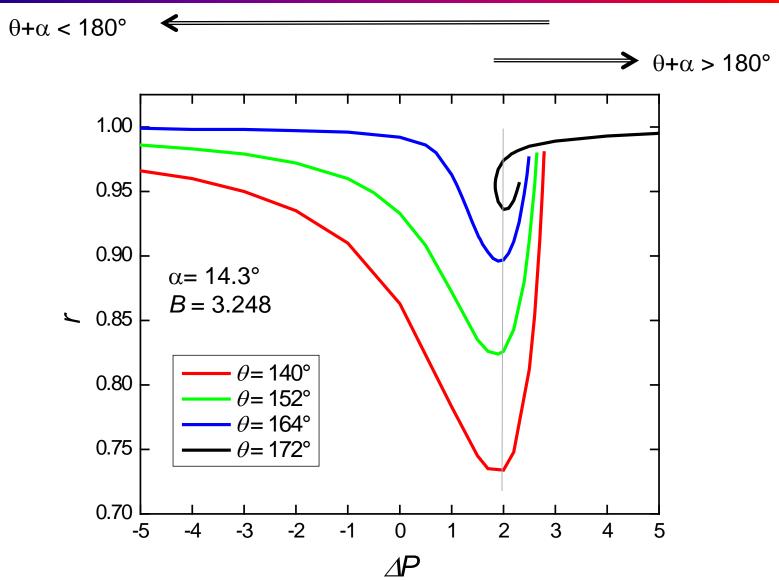
 α : growth angle

θ: contact or wetting angle



Gap Width vs. Pressure Differential (Ge at 1g)

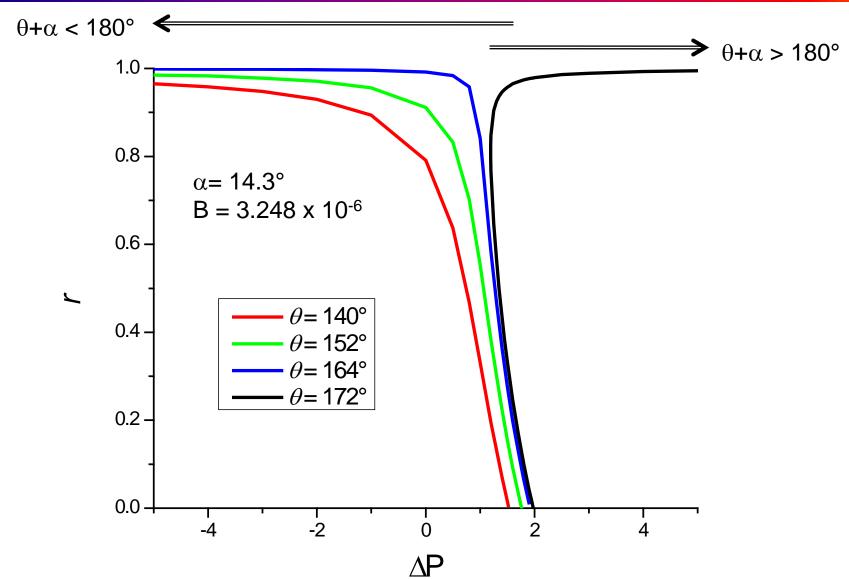






Gap Width vs. Pressure Differential (Ge at 10⁻⁶ x g₀)



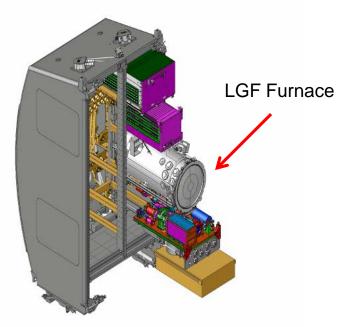




ICESAGE Flight Investigation



- "Influence of Containment on the Growth of Silicon-Germanium" (ICESAGE) is a collaborative investigation between NASA and the European Space Agency (ESA)
- The ICESAGE experiments will be conducted in the Low Gradient Furnace (LGF) in the Materials Science Laboratory on the International Space Station (ISS)
- Processing parameters will be varied to asses their affect on detachment
 - Sample Material (GeSi, Ge:Ga)
 - Affects the growth angle
 - Comparison of semiconductor alloy and doped element
 - Inner Ampoule surface material (SiO₂, boron nitride)
 - Affects the contact angle
 - Pressure: positive, negative, or zero (vacuum) gas pressure below the meniscus



Materials Science Laboratory



Microgravity Effects



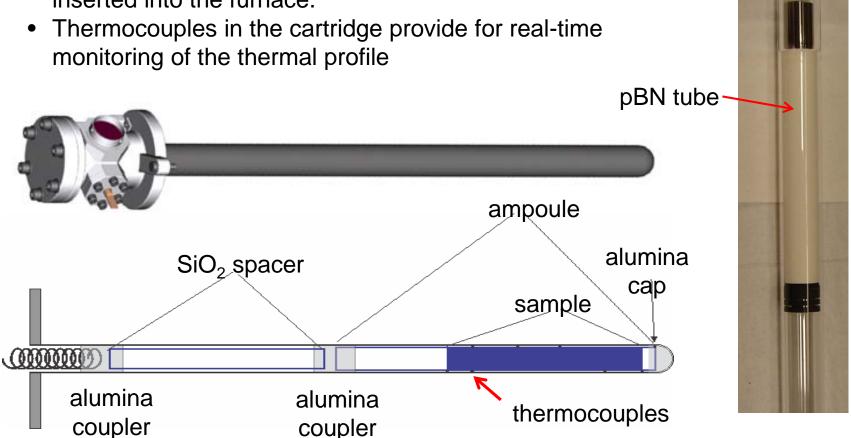
- Microgravity reduces the pressure head (ρgh) resulting from the weight of the melt.
 - Detached growth requires that capillary forces dominate over gravitational forces.
 - On Earth, gravity complicates a comparison of detached growth theory and experiment: the pressure head continuously decreases as the melt solidifies and the pressure varies along the height of the meniscus.
- Microgravity allows a larger value of the gap width.
 - On Earth, when the gap width becomes too large, gravity overcomes surface tension, a stable meniscus cannot be maintained, and the melt will flow down between the crystal and ampoule wall.
 - A large initial gap width will allow measurement of anisotropy in the growth angle.
- Microgravity enables a study of the dynamic stability of crystallization independent of thermal effects.



Ampoule and Cartridge Layout



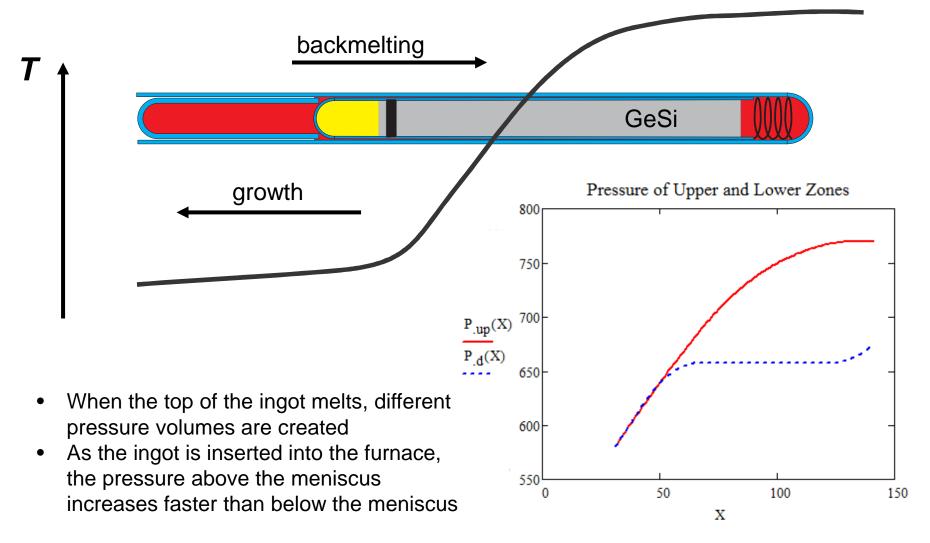
- A Ge_{1-x}Si_x ingot is placed inside a pyrolitic boron nitride (pBN) tube and sealed in a SiO₂ ampoule.
- The ampoule is placed inside a cartridge which is inserted into the furnace.





Positive Pressure Configuration

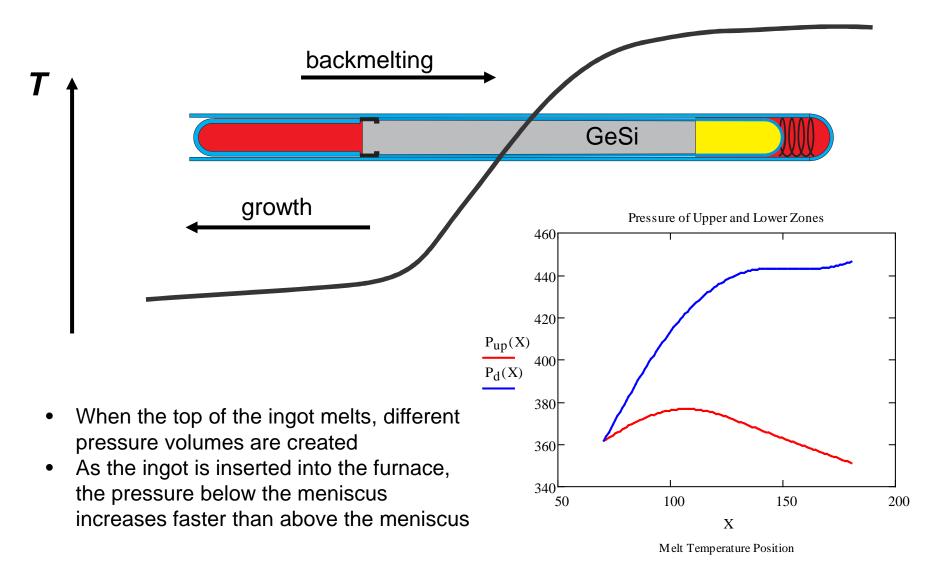






Negative Pressure Configuration







Summary



- Crystals grown by the detached Bridgman method have greatly increased crystalline perfection, motivating a systematic study of the phenomenon
- A theory describing the conditions for detachment has been developed
- Only crystals where $\alpha + \theta > 180^{\circ}$ are expected to achieve stable detached growth in microgravity
- Reproducible detached growth has been achieved in the laboratory under limited conditions
- Microgravity will allow the study of detachment over a range of parameters not possible to achieve on Earth
- A series of Ge and GeSi crystal growth experiments are being developed for processing on the ISS